

Numerical Analysis of Electrical Characteristics in a Squared Channel EHD Gas Pump

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Abstract

Corona discharge characteristic is highly dependable on working medium, the system setup, and the ambient condition. With a numerical analysis, the impact of high voltages on the electrical characteristics during EHD (electrohydrodynamic) pumping in a square channel is investigated with a wide range of high applied voltages. The conductor setup is settled with three types of pin configuration. Also, each conductor is tested for three different width ground plates. Simulation model consists of a conductor, ground plate, and square flow channel (6.0-inch). The material for the square channel is glass; copper is selected for both conductor and ground plate. The results of the numerical study showed that the use of different numbers of conductor pin and change in ground plate width have a great impact on the EHD electrical characteristics with a significant deviation of forces on ground plate, conductor, test region and square channel are found.

Index terms— corona wind, electrohydrodynamic, ionic flow, ansoff maxwell, numerical analysis, FEM, force flow.

1 Introduction

hen a gas discharged from the place where geometry confines the gas ionizing processes to high-field ionization regions around an active electrode [1](Goldman, A. Goldman, and Sigmond, 1985). The American Standards Association defines "Corona is a luminous discharge due to ionization of the air surrounding a conductor around which, exists a voltage gradient exceeding a certain critical value" [2](What is Corona? Hubbell Power System, 2004).

So far two types of flow generated per the working principle. One is displacement type and another one is a dynamic type [3] (Laser and Santiago, 2004) which distinguishes between the reciprocating and continuous flow [4] (Chen, 2005).

Corona discharge mainly occurred with two asymmetric electrodes, one of its very sharp on curvature shape (needle, pin or wire) and another one has a very curvy geometry (rod or plate). The curved electrode contains a very high charge potential which is created by supplying a very high voltage from an outer source. By creating a plasma state, the electrode with high curvature ionized the nearest gas molecules which tend to migrate to the ground low curved electrode and this procedure is fully controlled by Coulomb force. Coronas can be either positive or negative. The voltage supplied to the curved electrode determines whether it is positive or negative. If the voltage supplied to the electrode is positive the corona discharge is positive otherwise it is negative if the supplied voltage is negative.

The ionized ions generate thrust on the other molecules near them by creating a collision while they try to move to the ground plate (low curved electrode). This continuous migration process creates a bulk flow, which is called ionic wind or corona wind (Fig ??). Year 2017 F Author ??: Lamar University, USA. e-mail: rezas.arena@gmail.com Figure ??: A basic schematic diagram for Corona wind generation with corona discharge [5] ??Genuth, 2013).

44 **2 II.**45 **3 Experimental Setup**

46 The main design parameters followed here is the same as [6] (Mazumder and Lai, 2014), two stage EHD pumping
47 procedure, but for this type of study, we only consider a single stage model. A glass box is the main structure
48 where the other apparatuses are mounted. This box also works as a passage to the EHD flow which is induced
49 after providing very high voltage and reaches the initial limit. Other main two parts of this setup are a conductor
50 (emitter pin) and ground plate.

51 In this study, the whole design procedure is done using PTC Creo Parametric 3.0 m010. The main glass box is
52 taken with an inner dimension of 4 in by 4 in by 12 in. The thickness of the glass is 0.25 inches. The conductor is
53 made with copper material of 20 GA which gives this wire a diameter of .032 inches. The Ground plate thickness
54 is 0.025 inches. The emitter pin is also made with the same copper wire and their length is 1.0 inches from the
55 top to the ground plate. Whole conductor setup is attached to the glass box just 1.0 inches below the top of the
56 box see fig 2.6. The gap between the conductor and ground plate is 2.5 inches that also concludes that the pin
57 end point to the ground plate beginning is 1.5 inches (Fig 2 ??6), this gap is necessary to achieve the successful
58 EHD pumping. Three types of the ground plate, as well as three types of conductor setup, are used in this study.
59 The ground plate with a height of 0.5 inch, 1.0 inch and 2.0 inch and conductor with 4 pins, 12 pins, and 28 pin
60 emitters are considered and designed for this numerical analysis process. Cases of study 4 pin conductor with 0.5
61 inch of groundplate. 4 pin conductor with 1.0 inch of groundplate. 4 pin conductor with 2.0 inch of groundplate.
62 12 pin conductor with 0.5 inch of groundplate.

63 12 pin conductor with 1.0 inch of groundplate. 12 pin conductor with 2.0 inch of groundplate. 28 pin conductor
64 with 0.5 inch of groundplate. 28 pin conductor with 1.0 inch of groundplate. 28 pin conductor with 2.0 inch of
65 groundplate.

66 **4 Theory and Simulation Set Up**

67 The electrostatic theory is derived from Gauss's Law and from Faraday's law of induction. Gauss's Law shows
68 that the net electric flux passing through any closed surface is equal to the net positive charge enclosed by that
69 surface. This derives that in differential format? ?? = ??(1)

70 Here ?? (x, y) is the charge density. We also know that the charge density can be pulled out by multiplying
71 the relative permittivity ? r , ? o is the permittivity of free space, 8.854×10^{-12} F/m and Field Intensity E.
72 So, we can conclude with another equation:?? = ? r ? ? o ? ? (2)

73 With the help of Faraday's law of induction, it is known that?? = ?? ? ? (3)

74 Where ? (x,y) is the electric potential. So, the final field equation is? (? r ? ? o ? ? ? (x, y)) = ? (4)

75 This is the equation that the electrostatic field simulator solves using the finite element method.

76 To analyze the results a datum line is created by Maxwell just in the middle of the model with a total height
77 of 6-inch top to bottom. This datum line is used to create the data plots after finishing the simulation process.
78 Also, parameters like force, torque, and matrix distribution are set up on each part of the model to get the final
79 output after final pass in the simulation process. An empty box is created just in the middle of the main canal to
80 cover the highest maximum volume to get a visual of voltage, charge, electric field distribution after completing
81 the simulation work.

82 Solution setup is the main part before starting the solution, where we can put the percentage of error, we will
83 allow in this particular study with the number of passes allowed. Here we put the percentage of error allowed is
84 0.5 % with a number of passes 10 for all cases. So, the Maxwell software will perform the passes till it reaches
85 the error percentage allowed. If we put the whole procedure in a flow chart we can conclude with the below flow
86 chart.

87 IV. For each type of Ground plate setup, it is created single case, so for 0.5-inch, 1.0-inch and 2.0inch ground
88 plate 3 types of pin combination taken each time to build 3 fields of study. For 0.5-inch ground plate the far most
89 position found for 12 pin conductor set up and closest found for 4 pin conductor. 1.0-inch ground plate setup
90 showed interesting data that both 4 and 28 pin setup have the same point of highest intensity, but both of them
91 went far from the point they have for 4 pin setup, 12 pin setup in this case lacked behind from both of them and
92 created the point nearest to the top with an increase from 0.5-inch ground plate setup. 2.0-inch ground plate
93 with 4 pin conductor has far most and 28 pin conductor closest points of electric field. So, it can be concluded
94 from table ??.1 that the far most point found for the 1.0-inch ground plate with 4 and 28 pin conductor setup.

95 **5 Results and Discussion**
96 **6 Electric Field Intensity**
97 **7 Highest Field Intense Position**
98 **8 VI.**
99 **9 Forces on Test Region**

100 It is already discussed that the test region is created inside the channel and the material is assigned as Air to
101 see the impact inside the channel which also worked as a working fluid domain. The table 4.2 indicates that the
102 forces in X-axis for 4 pins are always negative and comparatively larger than 12 pin and 28 pin conductor. As
103 the concern is the forces acting in the positive Z-axis direction as it has the potential to create the force which
104 can drive the fluid from top to bottom of the channel. For 4 and 12 pin the Z direction force is larger, but it is
105 negative, which means a very poor or negative potential to create the flow in the Z direction. Found forces here
106 are very low compared to the forces created in other parts of the experimental domain. For each pin set up for
107 every direction despite their positivity forces increase with the increase of voltage applied. The maximum total
108 force found in the 12 pin conductor setup which is 230 μN . As the forces in X or Y or Z axis found negative in
109 different cases which mean the force is not exerting on the outside of the channel it basically creating a collision
110 within the region. For 4 and 12 pin the X and Z axis force pushing inwards whereas the Y axis forces are exerting
111 on the region wall.

112 **10 Conclusion**

113 The present study has investigated the electrical characteristics of a square channel single stage EHD pump.
114 Three types of conductor (4, 12, 28 pin) are created and each conductor have three (0.5-inch, 1.0inch and 2.0-
115 inch) ground plate set up with the glass channel. A lost voltage always found for every applied voltage in a
116 conductor. The pattern of the charge distribution, electric field distribution and energy distribution are same
117 along the datum line. All the simulations are converged within the selected maximum number of pass and energy
118 error percentage (0.5 %). Tetrahedral meshes are created by the adaptive meshing system in each validation pass.
119 For the same number of pins if the width of ground plate is increased the percentage of ionized air is increased.
120 For the same ground plate width, it is found that the ionized air is increased if the pin number in conductor
121 increased. The electric field intensity is increased by the increment of the conductor pin number and width of
122 ground plate.

123 The far most point of highest electrical field intensity is the 1.0-inch ground plate with 4 and 28 pin conductor
124 setup. The position of the highest value of electric field gradually decreases from the top the channel if the pin
125 number is increased for 0.5-inch ground plate setup. Highest field intensity is found nearest for 12 pin conductor
126 with a 1.0-inch ground plate and for 2.0-inch ground plate nearest field intensity created for 28 pin conductor.

127 Forces acting on Ground Plate, Conductor and Channel are increased with if the applied voltage is increased,
128 which are independent of the width of ground plate, but also larger range of forces are found with the increase
129 of pin number. The experimental domain forces are very low compared to the forces. Forces are increased when
130 applied voltage increased despite their direction.

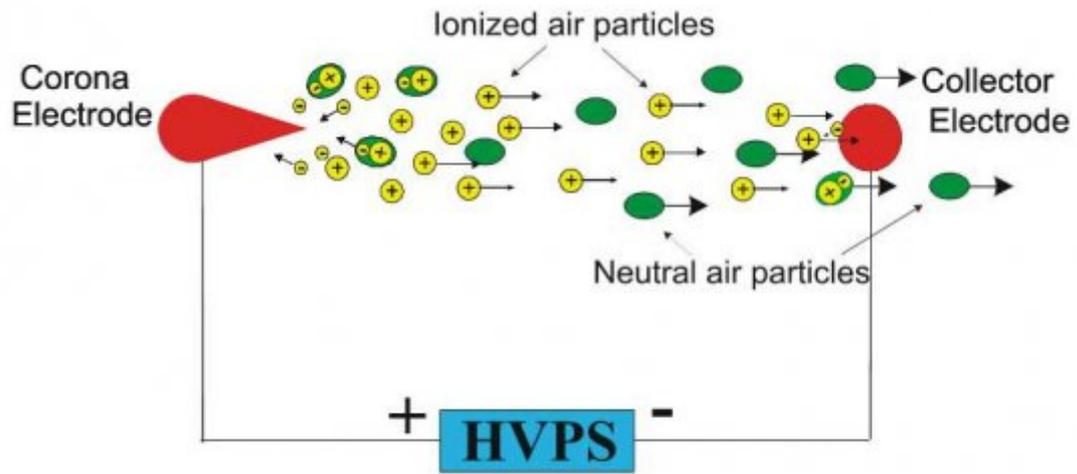
131 This study has opened a lot of opportunities to work on different shapes of sizes of EHD pump as the electric
132 field potential and forces are measured successfully. This same simulation can be tied up with ansys fluent. This
133 can be effective to find the flow pattern and flow velocity directly from the ionized air. Any kind of dielectric
134 fluid can be analyzed in micro scale. ^{1 2 3 4}

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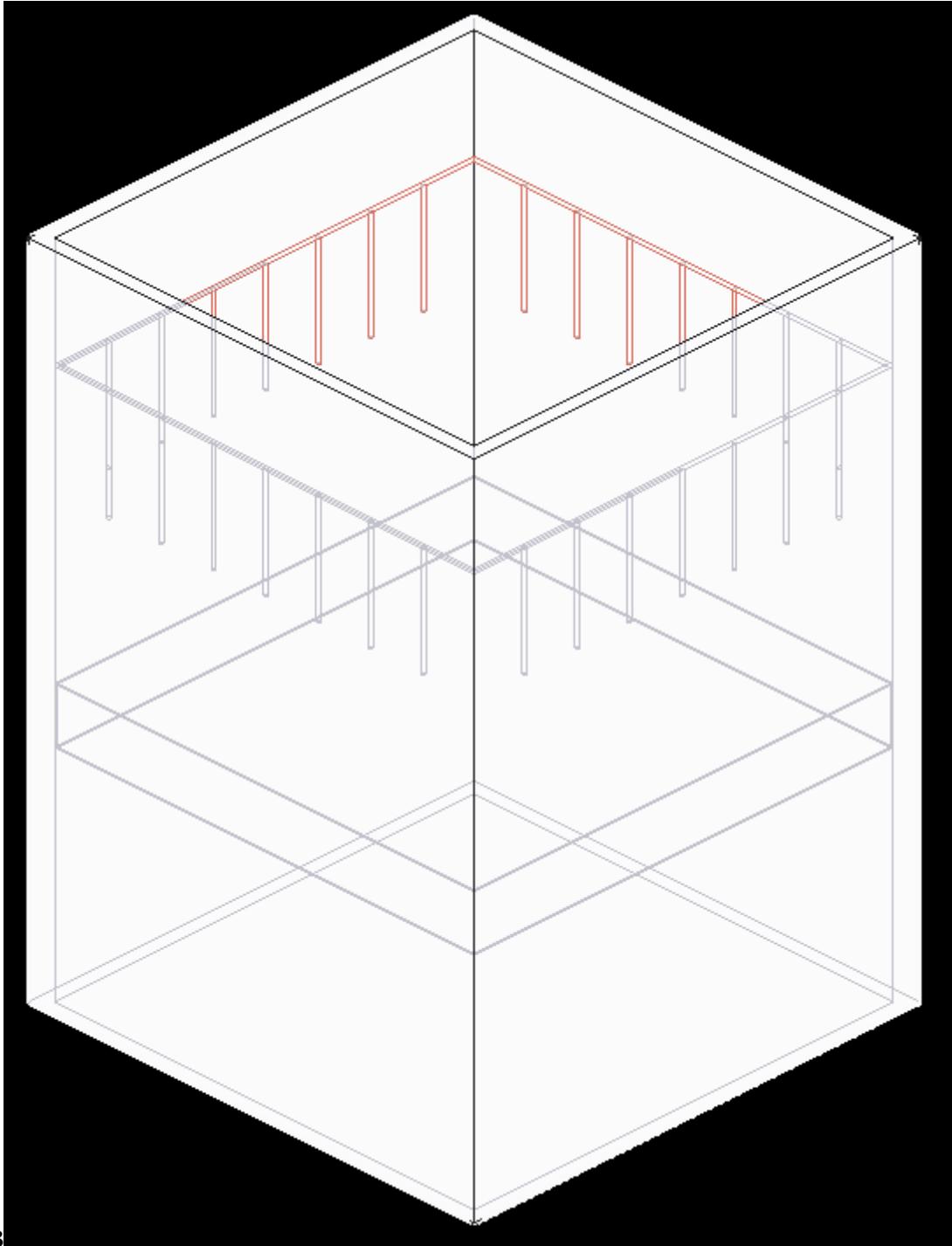
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⁴pin conductor © 2017 Global Journals Inc. (US)



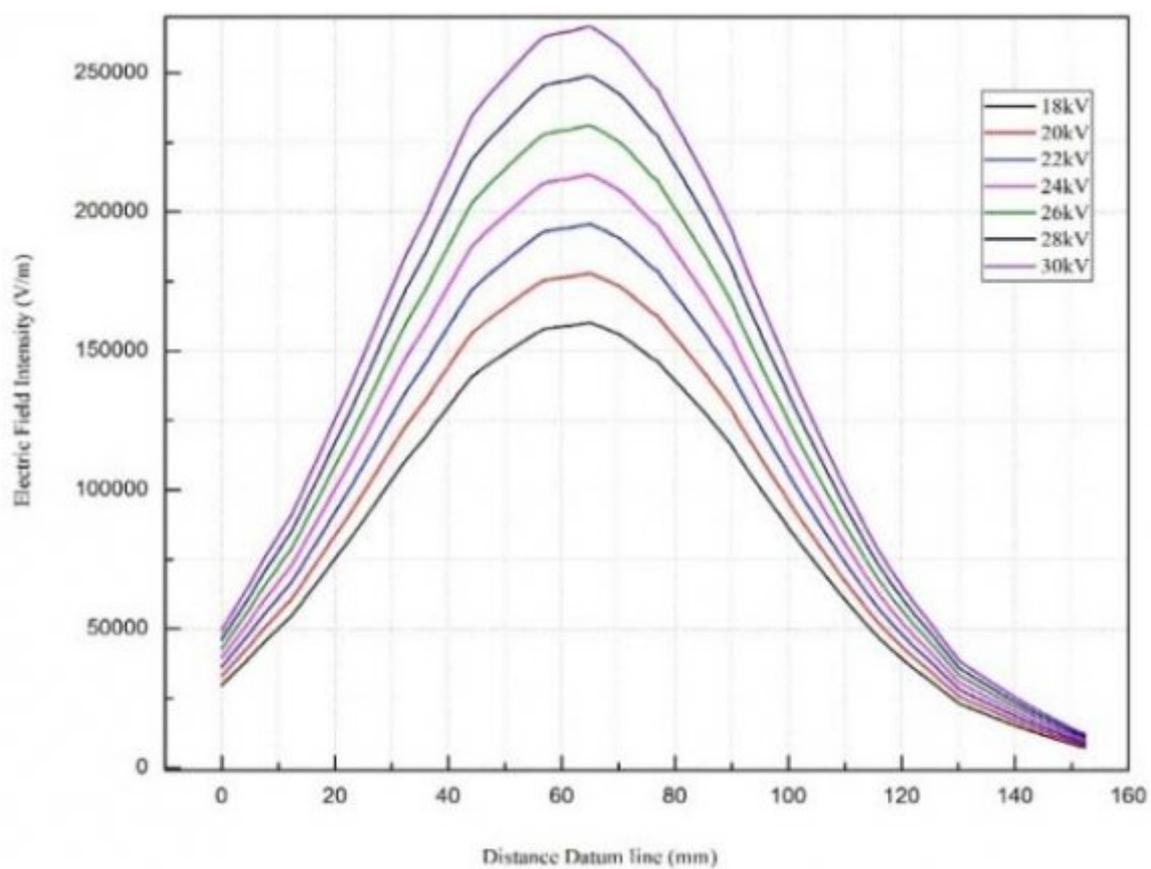
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Figure 1: Figure 2 :



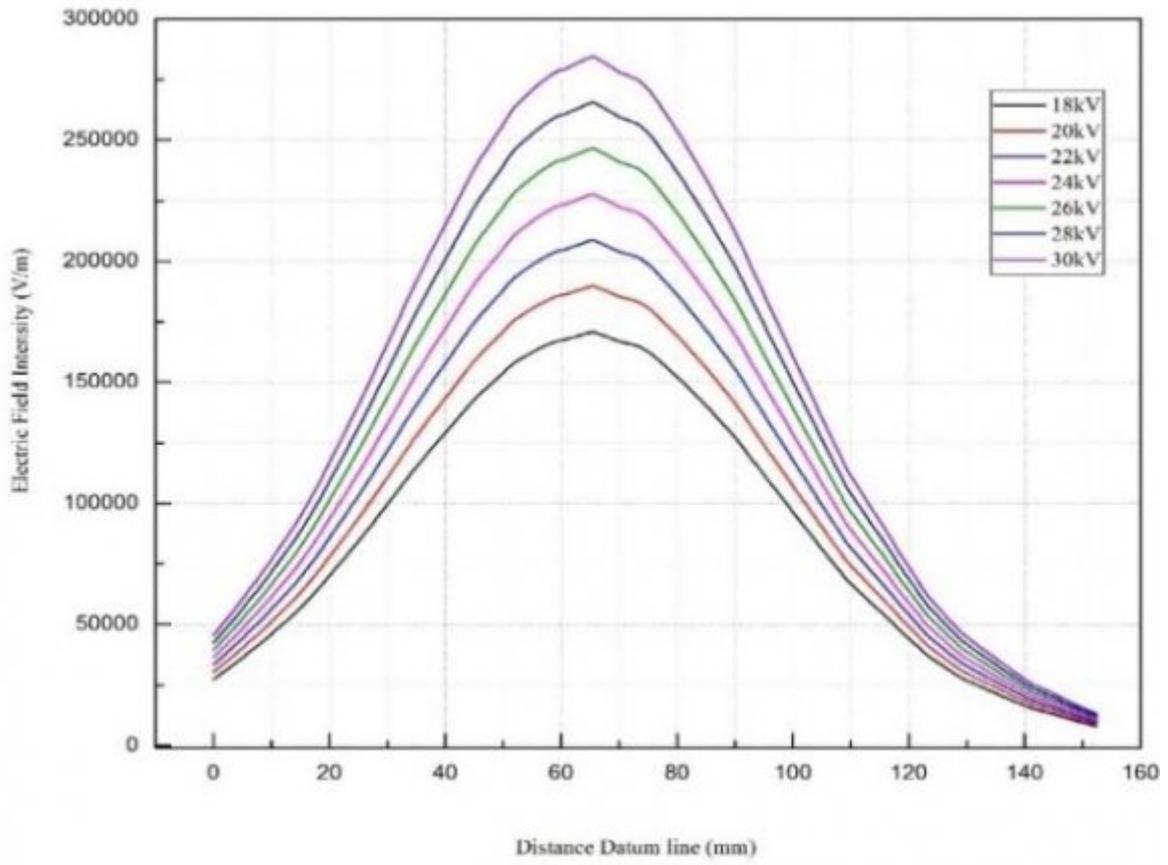
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Figure 2: Figure 3 :



4

Figure 3: Figure 4 :



5

Figure 4: Figure 5 :

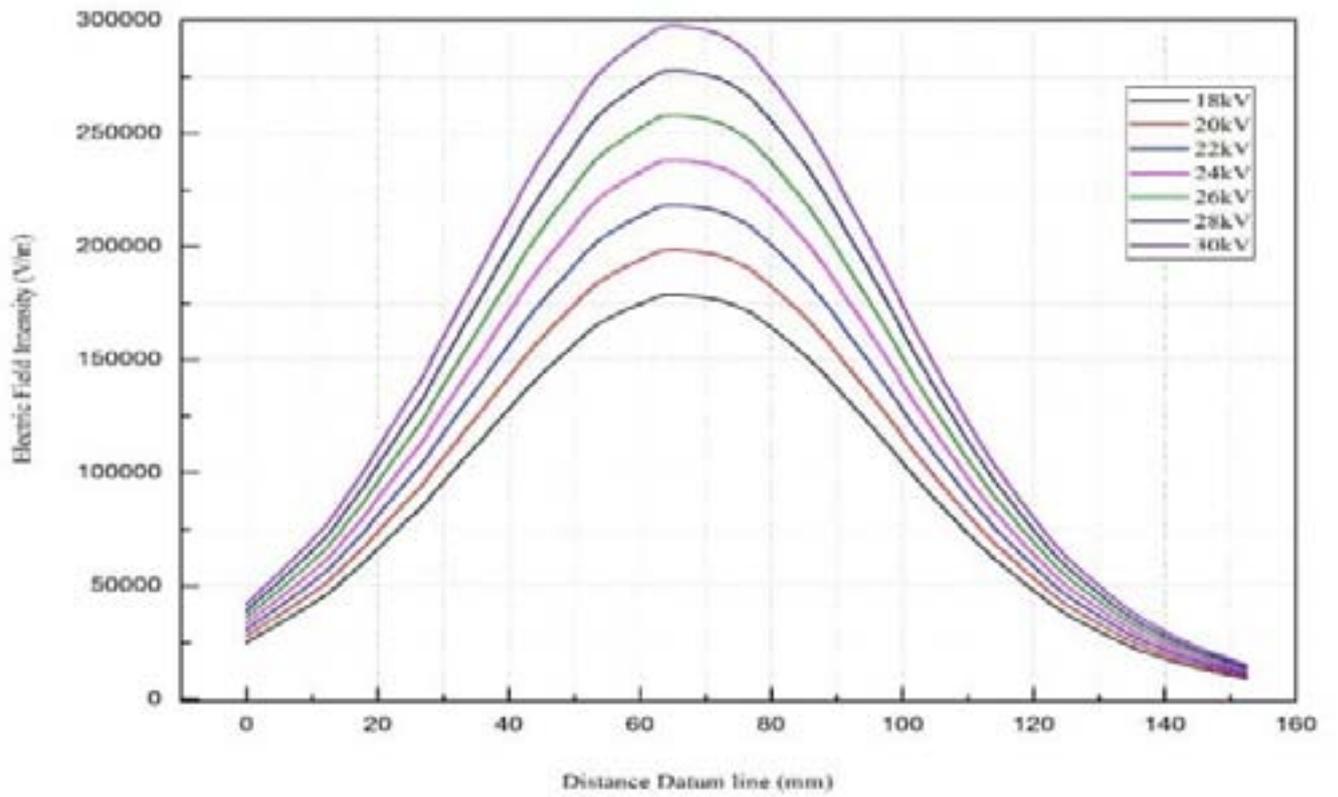


Figure 5:

1

Voltage	F Xv Force (μN)	F Y Force (μN)	F Z Force (μN)	Total Force (μN)	Conductor Typed
18	-59.437	26.893	-12.602	66.444	
20	-73.379	33.201	-15.558	82.029	
22	-88.788	40.174	-18.825	99.255	
24	-105.67	47.81	-22.404	118.12	
26 28	-124.01 -143.82	56.11 65.075	-26.293 -30.494	138.63 160.78	4 Pin Con- duc- tor
30	-165.1	74.703	-35.006	184.57	

Figure 6: Table 1 :

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